



Applied Precision

Pad Damage Management on the Test Floor

By John Strom – Lifetime Fellow

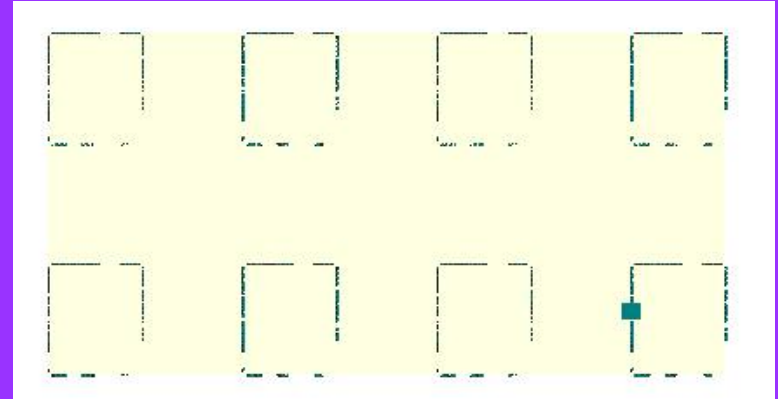
Agenda

- Overview of Test Setup
- General Analysis of Test Data
- Scrub Depth Analysis
- Punch-Through Analysis
- Bump Measurements
- Conclusions



Testing Overview

- Probe Card –
 - 8 Dut
 - 1208 Probes
- 300mm Prober / Wafer
- Metrology Tool - waferWoRx300
 - Probe Card Measurements - Planarity/Alignment/Diameter (Optical)
 - Wafer Measurements - 2D Scrub Measurements
 - Analysis - Correlation / Probing Process Modeling
 - 3D Scrub Measurements – Scrub Depth
 - 3D Probe Tip Measurements – Tip Profile
 - Punch Through Screening
 - Bump Measurements



General Analysis of Test Data

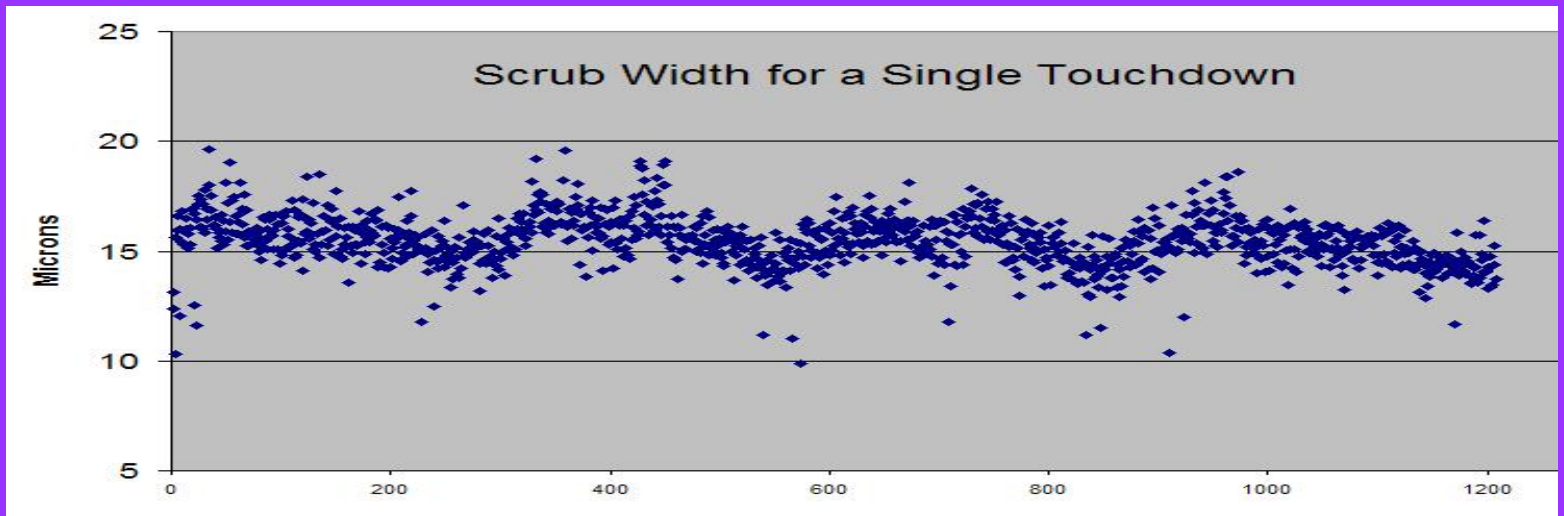
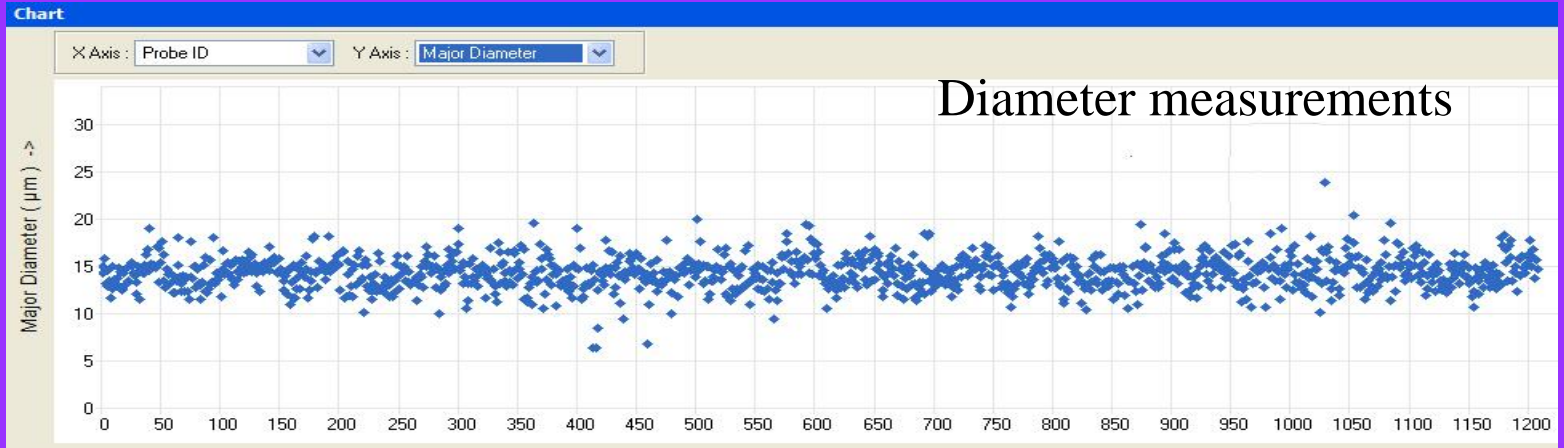
- Probe Card Measurements - (Position and Size)
- Wafer Scrub Measurements - (Position and Size)
- Correlation Analysis



Scrub Width and Tip Diameter

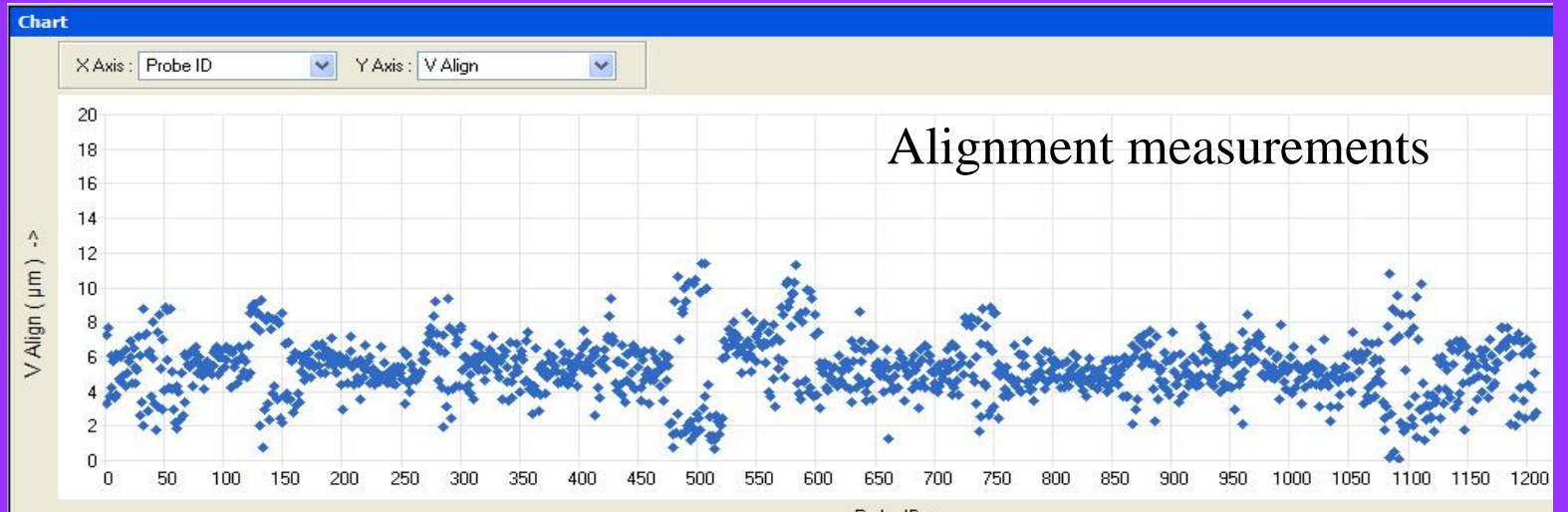
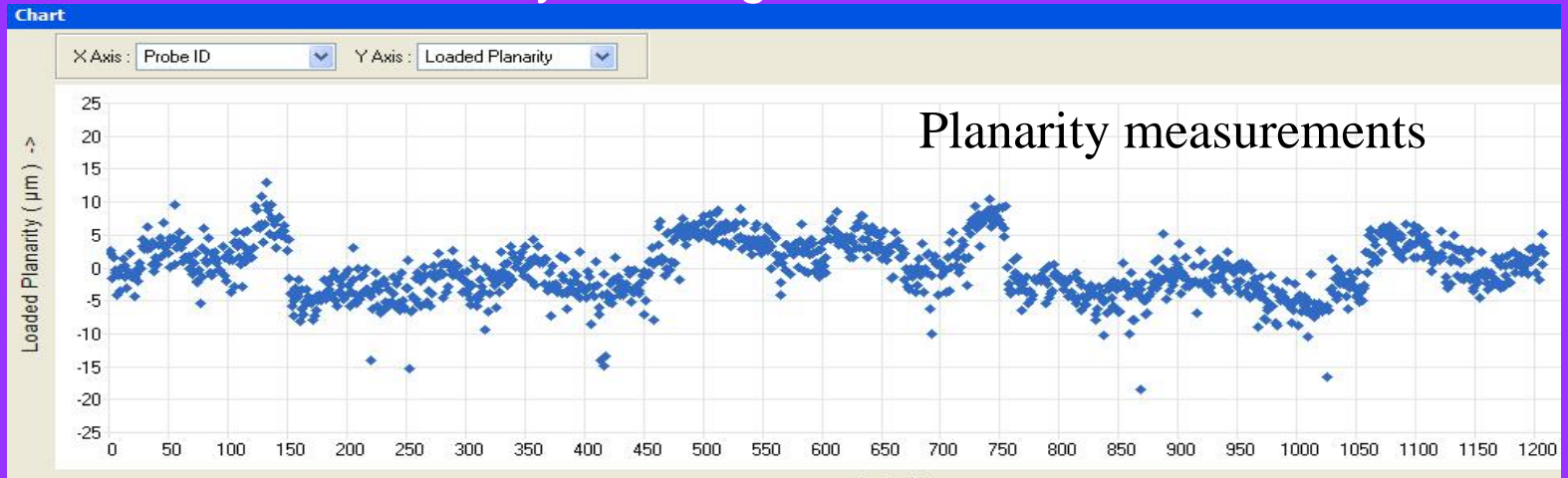
Probe Tip Diameter – Average = 14.3 microns

Scrub Width - Average = 15.5 microns



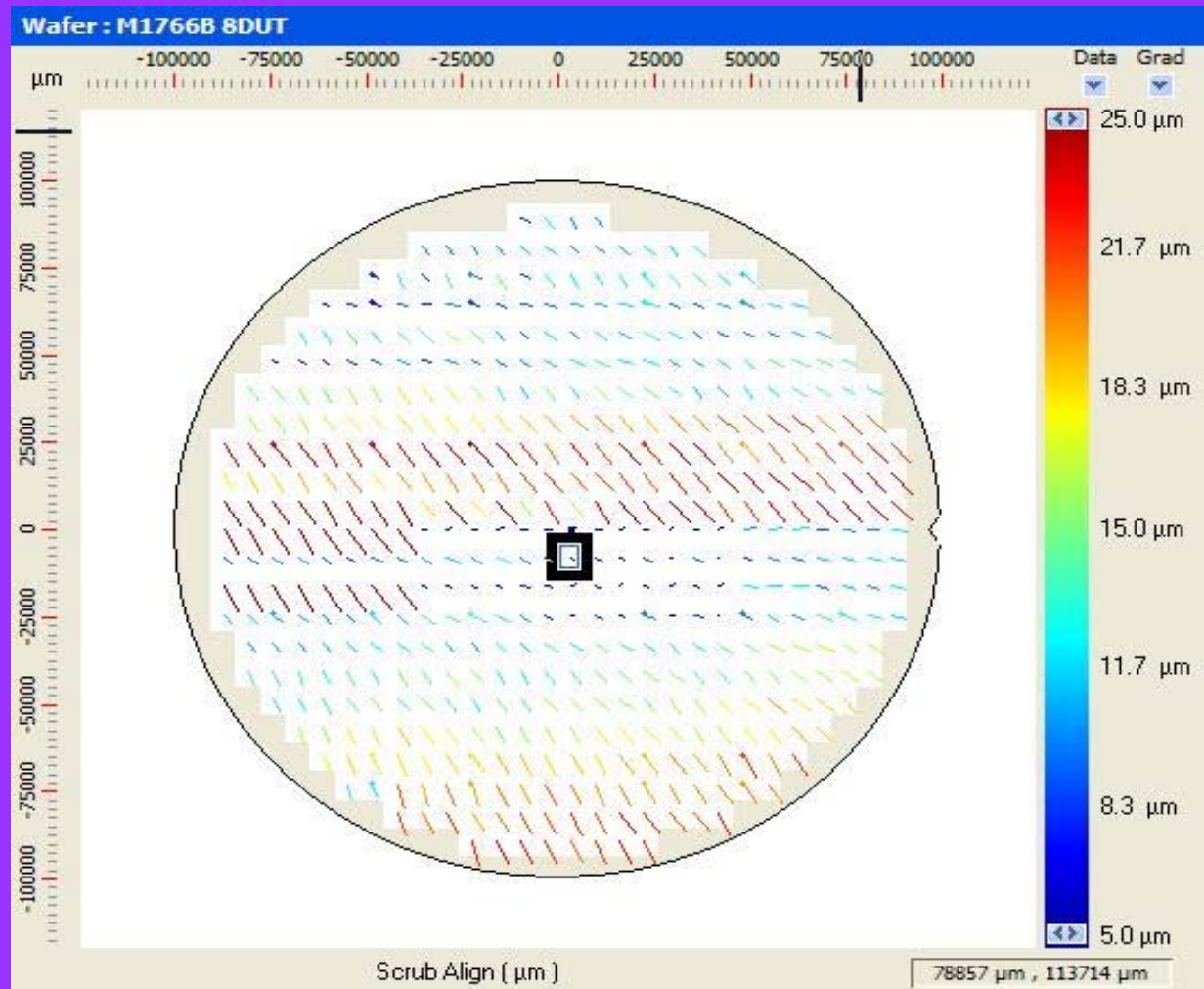
Probe Card : Position Measurements

Planarity and Alignment ~ 10 microns



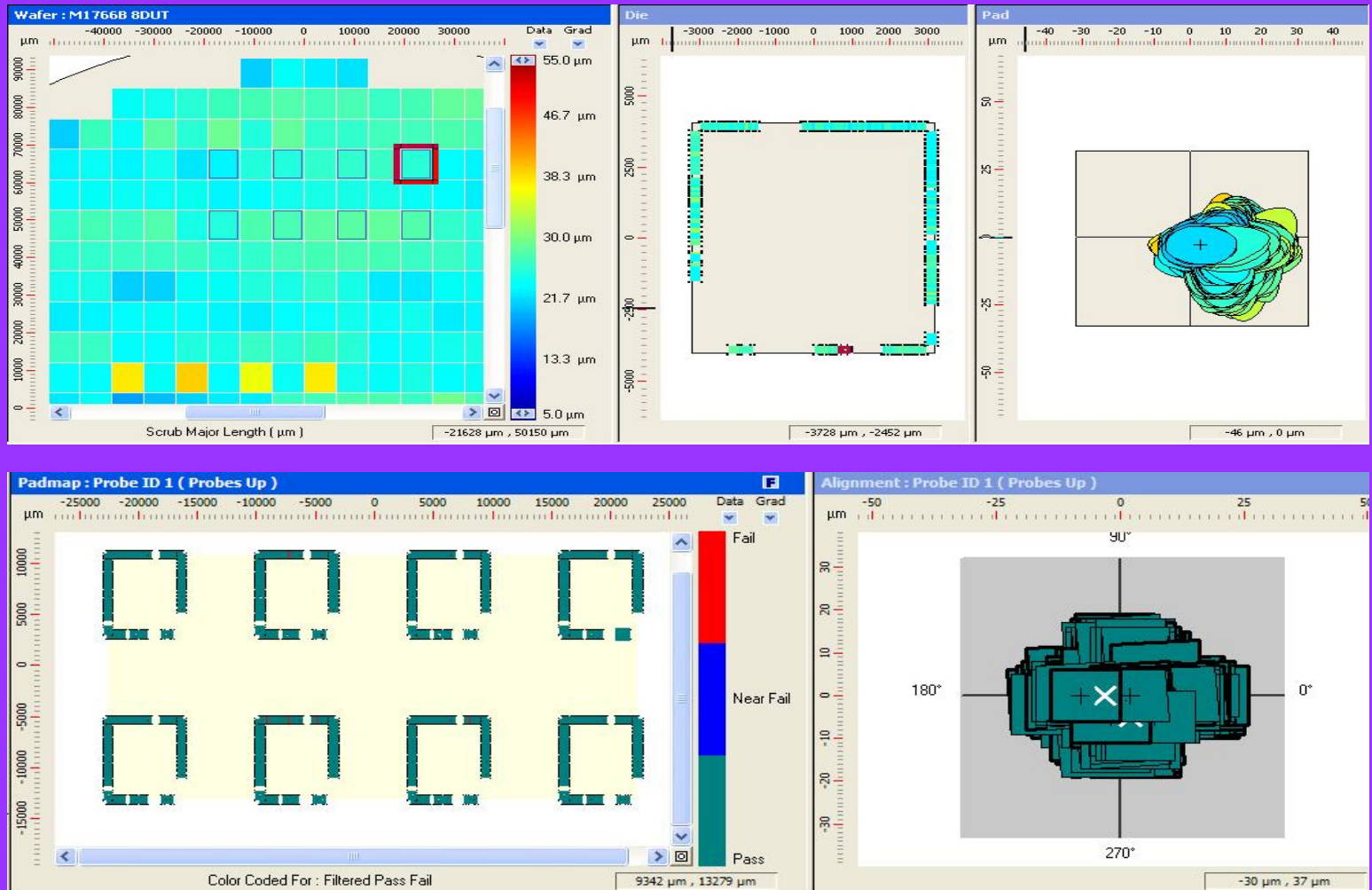
Wafer Measurements - XY

- Scrub XY Position - Vector View (Average XY Position per die)



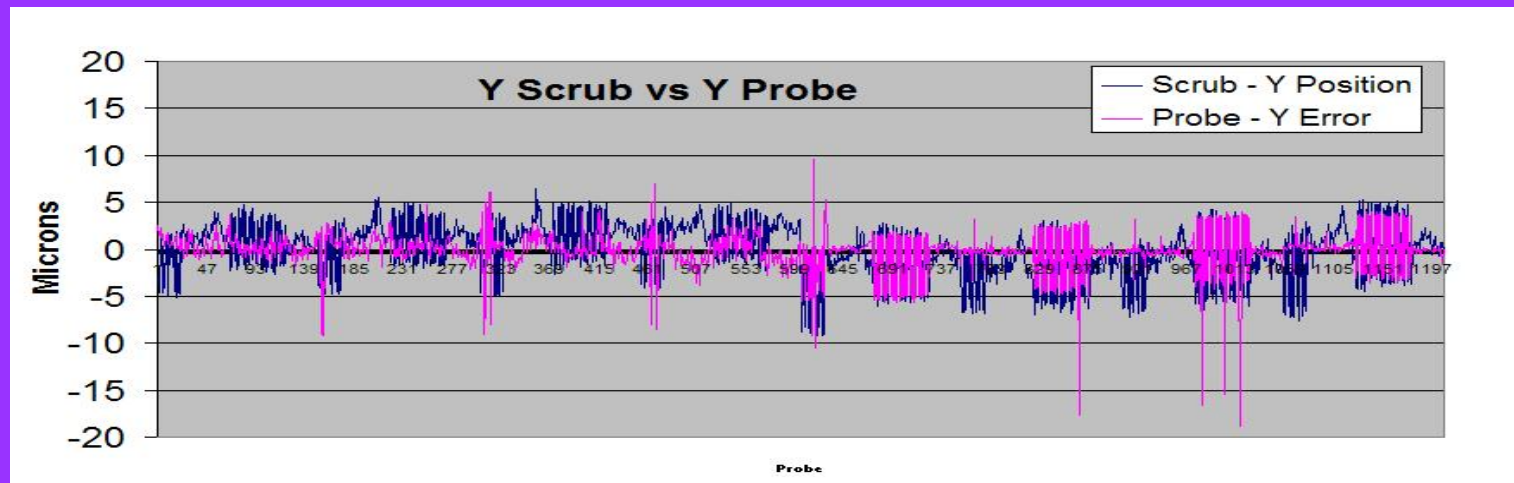
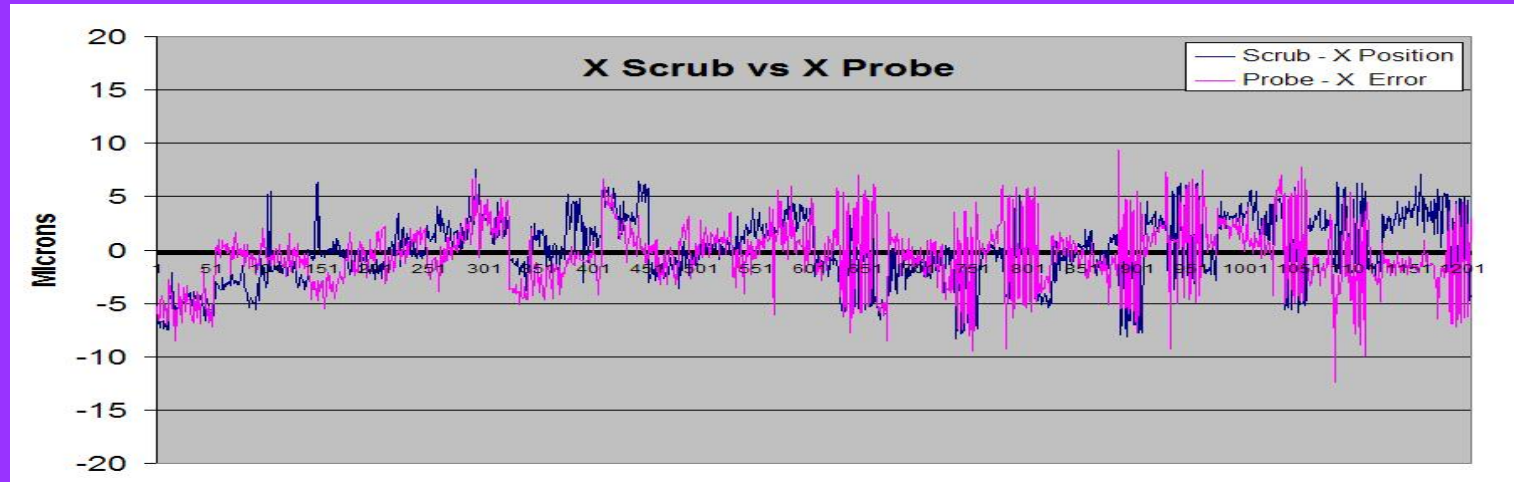
Wafer Measurements - XY

Scrub XY Position Predicted and Measured— Single Touch Down



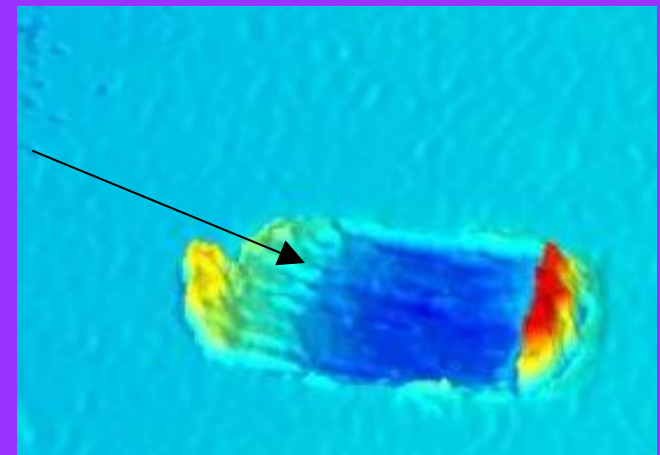
XY Correlation

Scrub XY Position Predicted and Measured— Single Touch Down

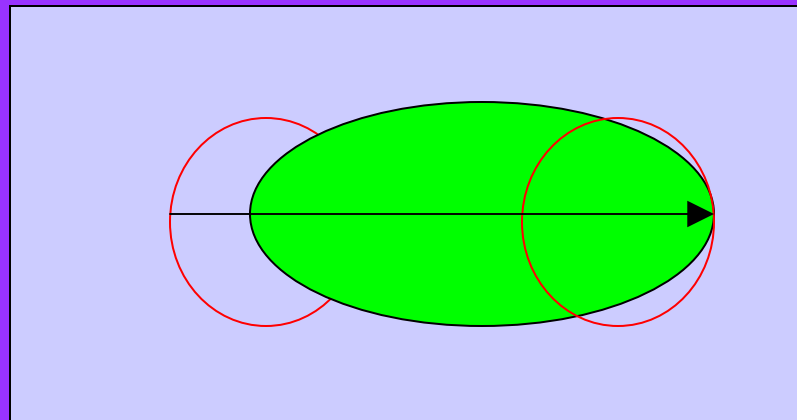
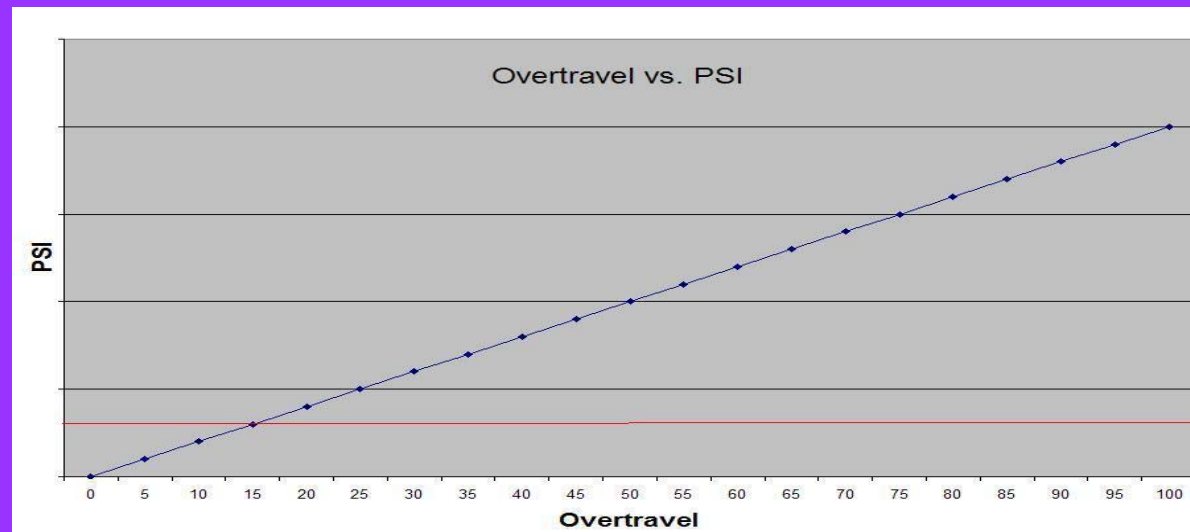


Scrub Depth Analysis Overview

- Pad Material and associated Yield Point
- Probe Tip Shape and Diameter vs Depth
- Scrub Length vs Depth

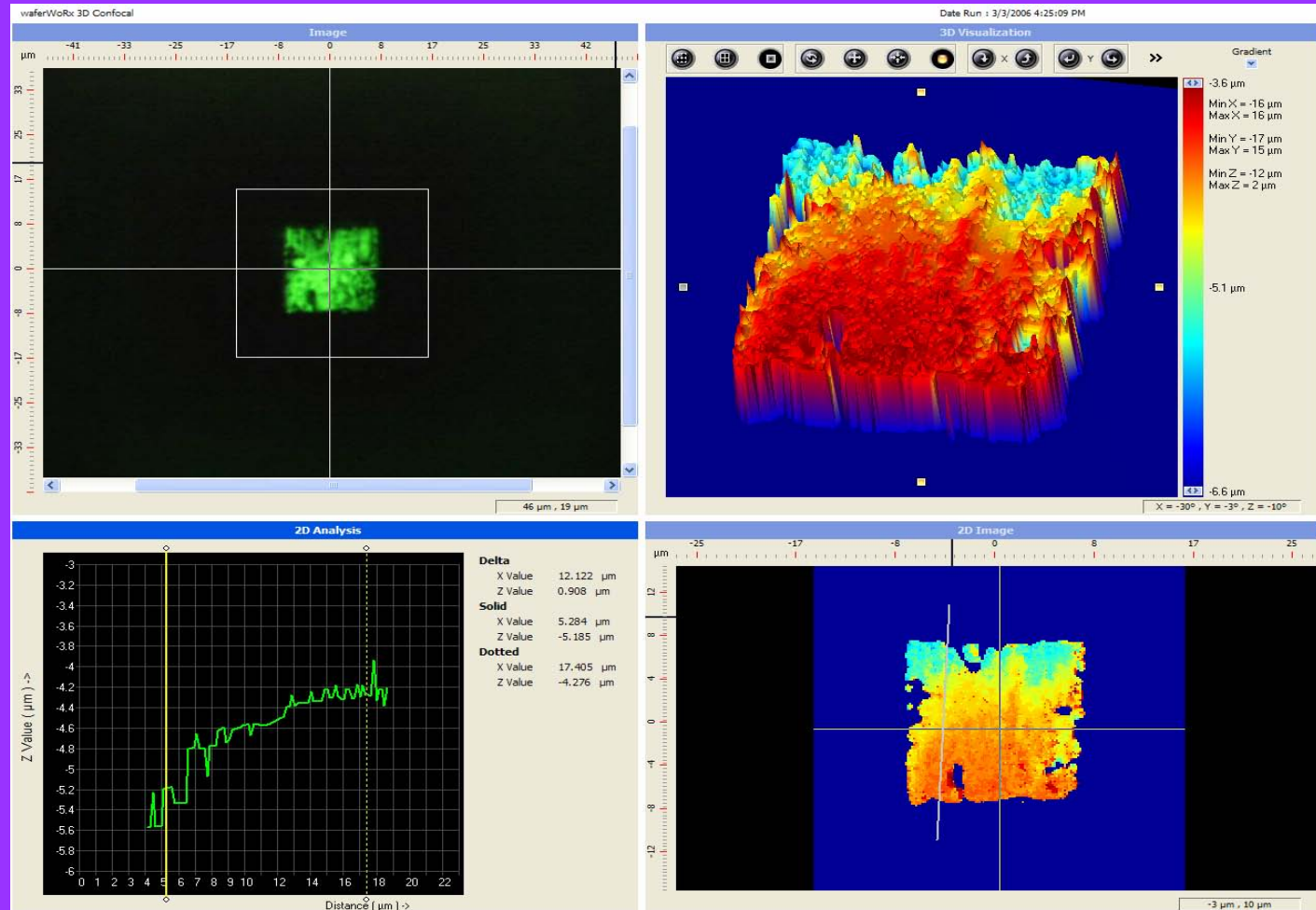


Pad Material and Associated Yield Point



Probe Tip Shape / Diameter

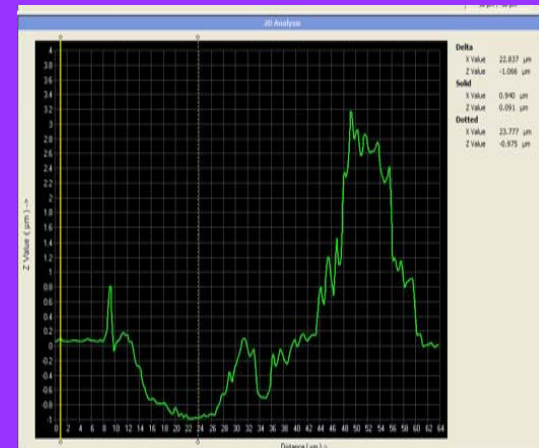
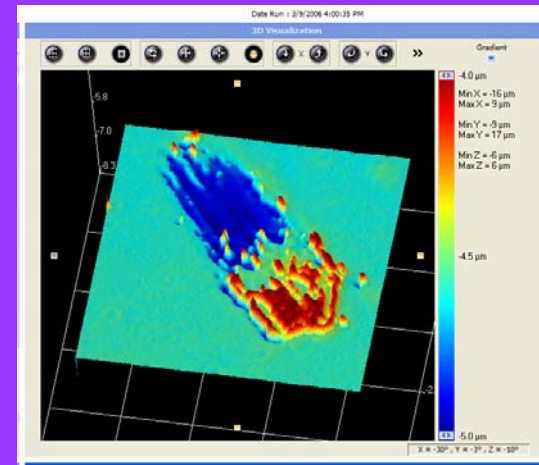
Consistent Shape and Size for majority of probes



3-D Scrub Depth Measurement

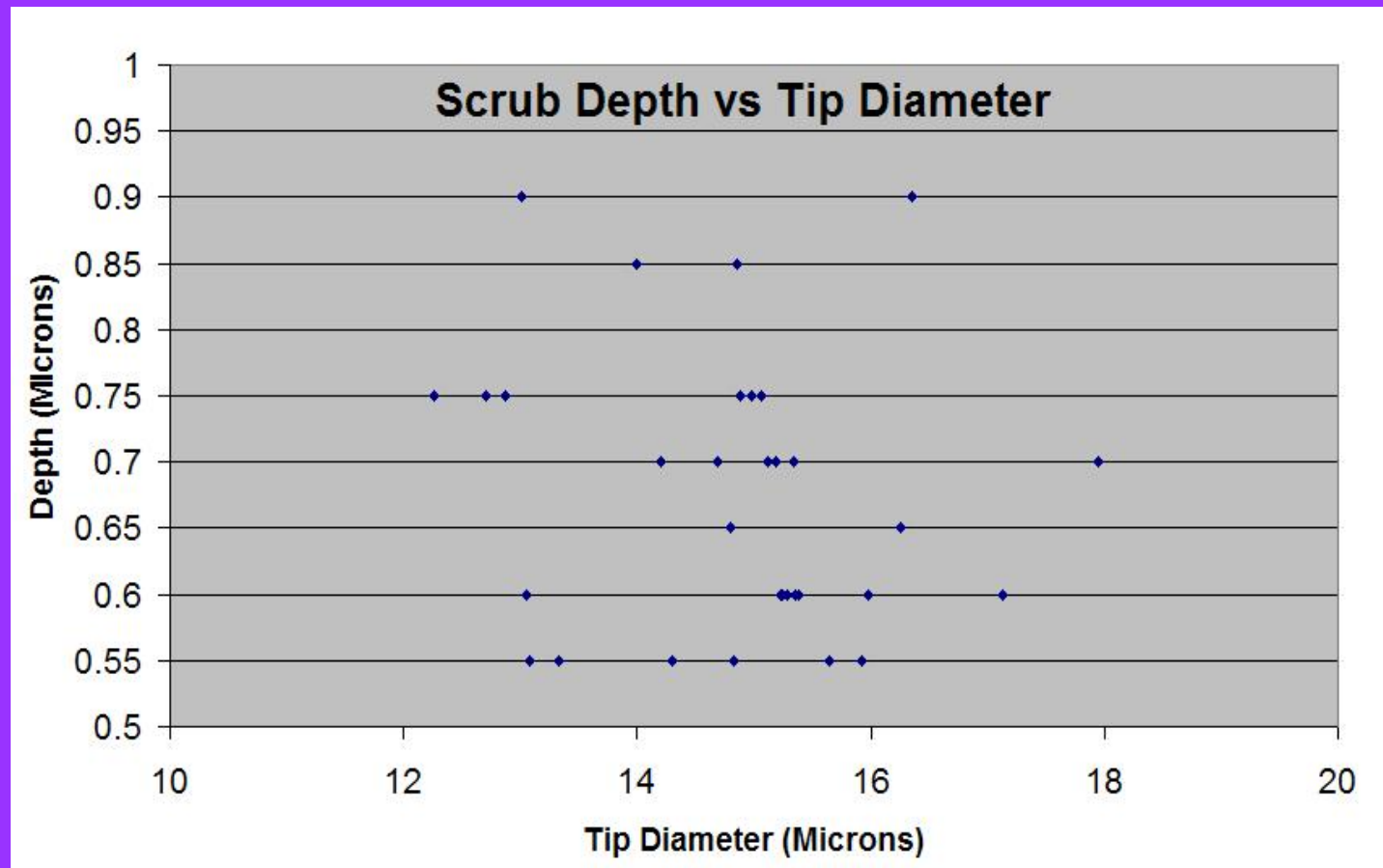
Complete 3-D
analysis of scrub
marks

Cross-sectional
analysis allows for
measurement
between any two
points



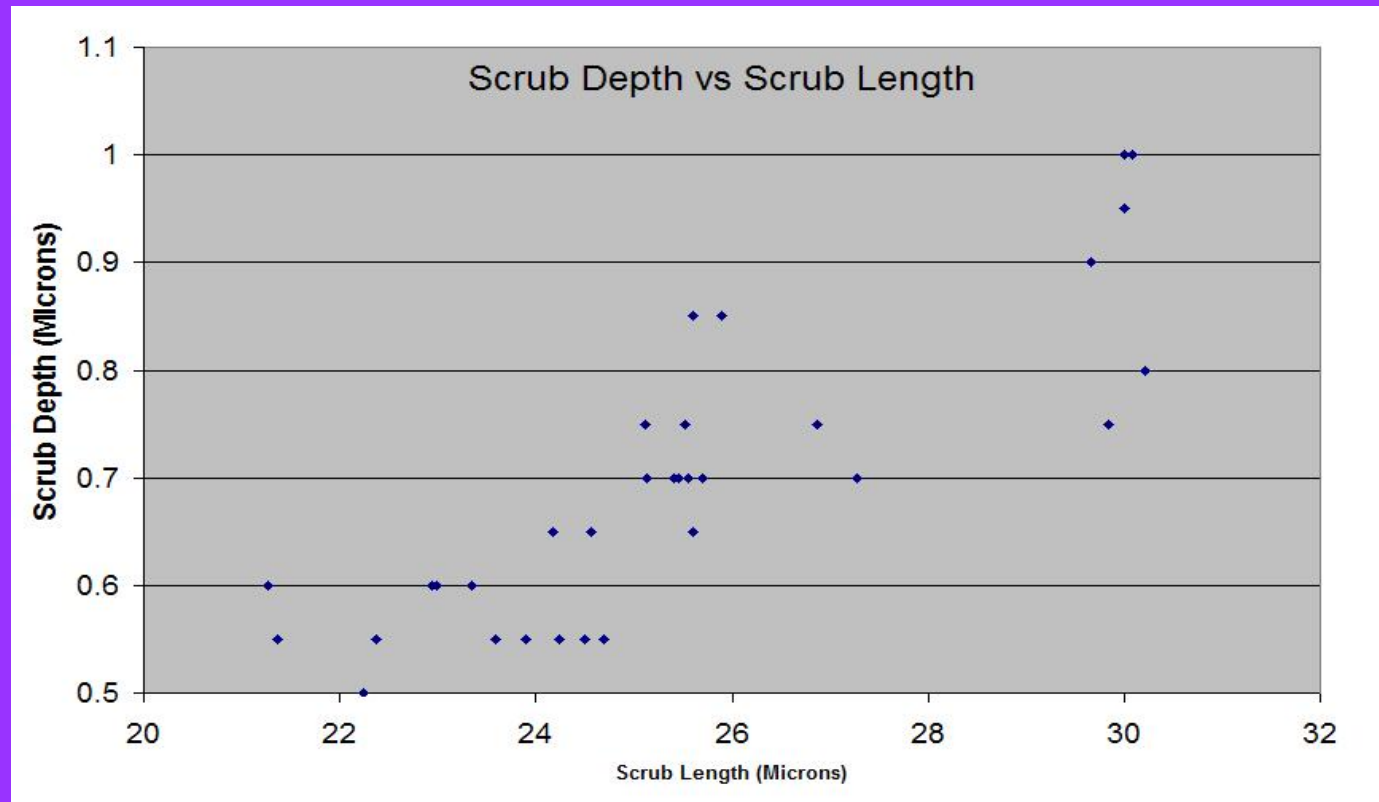
Scrub Depth vs Probe Diameter

Consistent Shape and Size caused very little depth correlation in this data set.

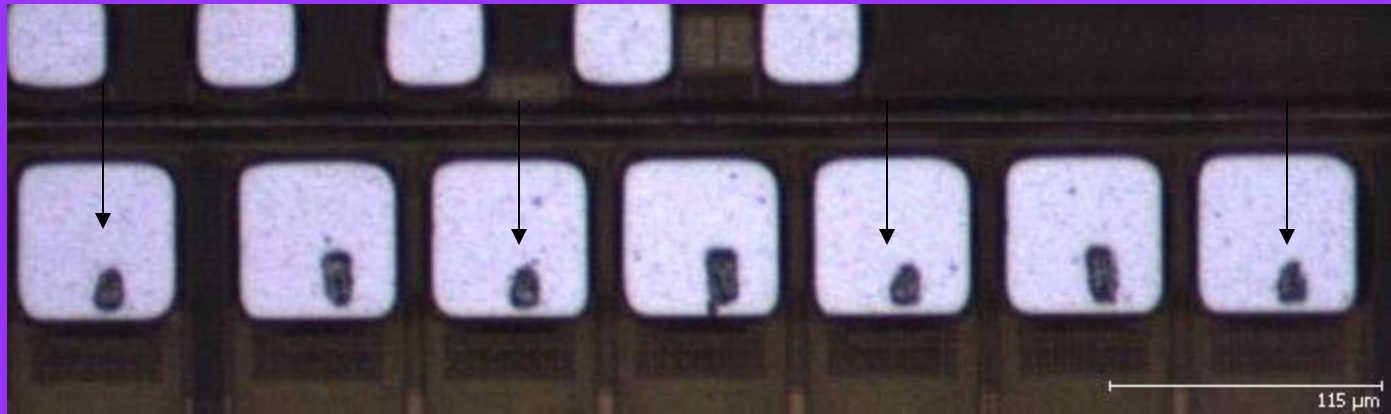


Scrub Depth vs Scrub Length

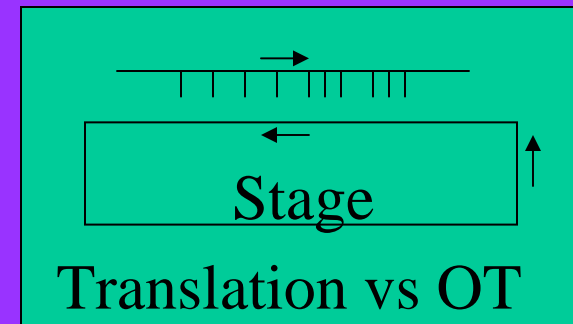
Strong correlation between Scrub Length and Scrub Depth



Scrub Depth vs. Scrub Length

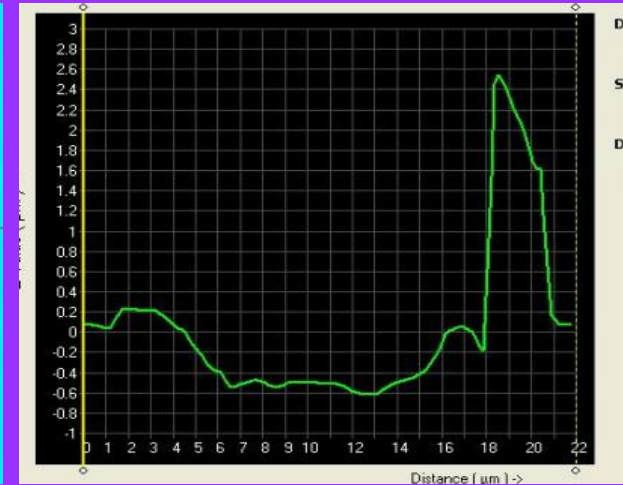
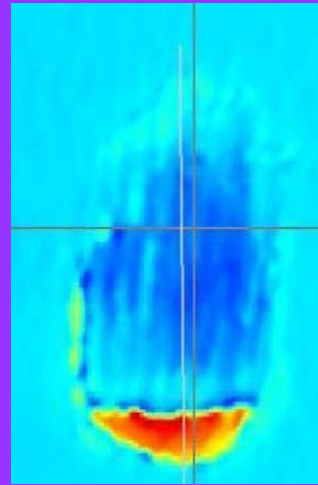


- Probes are planar
- Probes have same force
- Scrubs are longer/shorter because of translation of stage vs. card

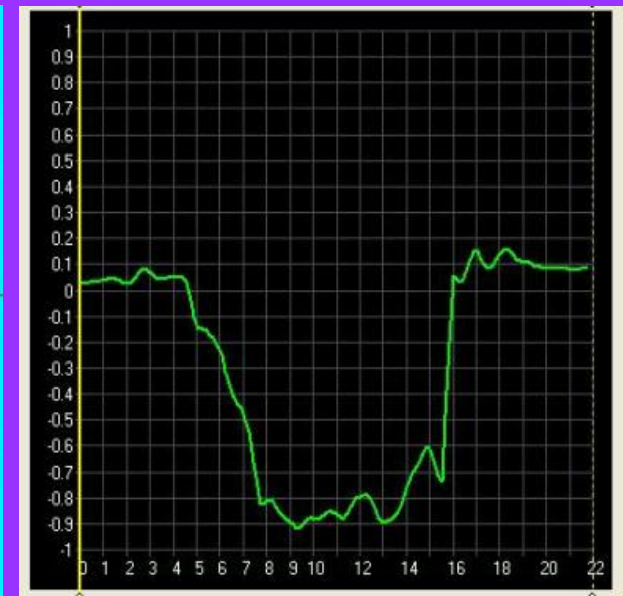
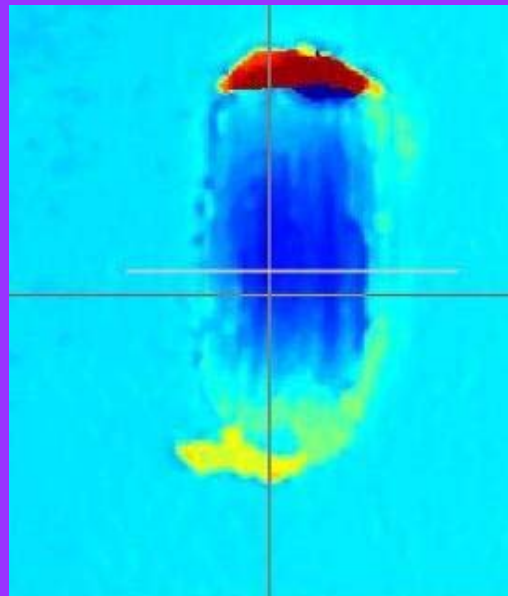


Scrub Depth vs Scrub Length

- Short Scrub
 - 22u Long
 - 0.6u Depth



- Long Scrub
 - 30u long
 - 0.9u Depth



What is Punch-Through?



June 2006

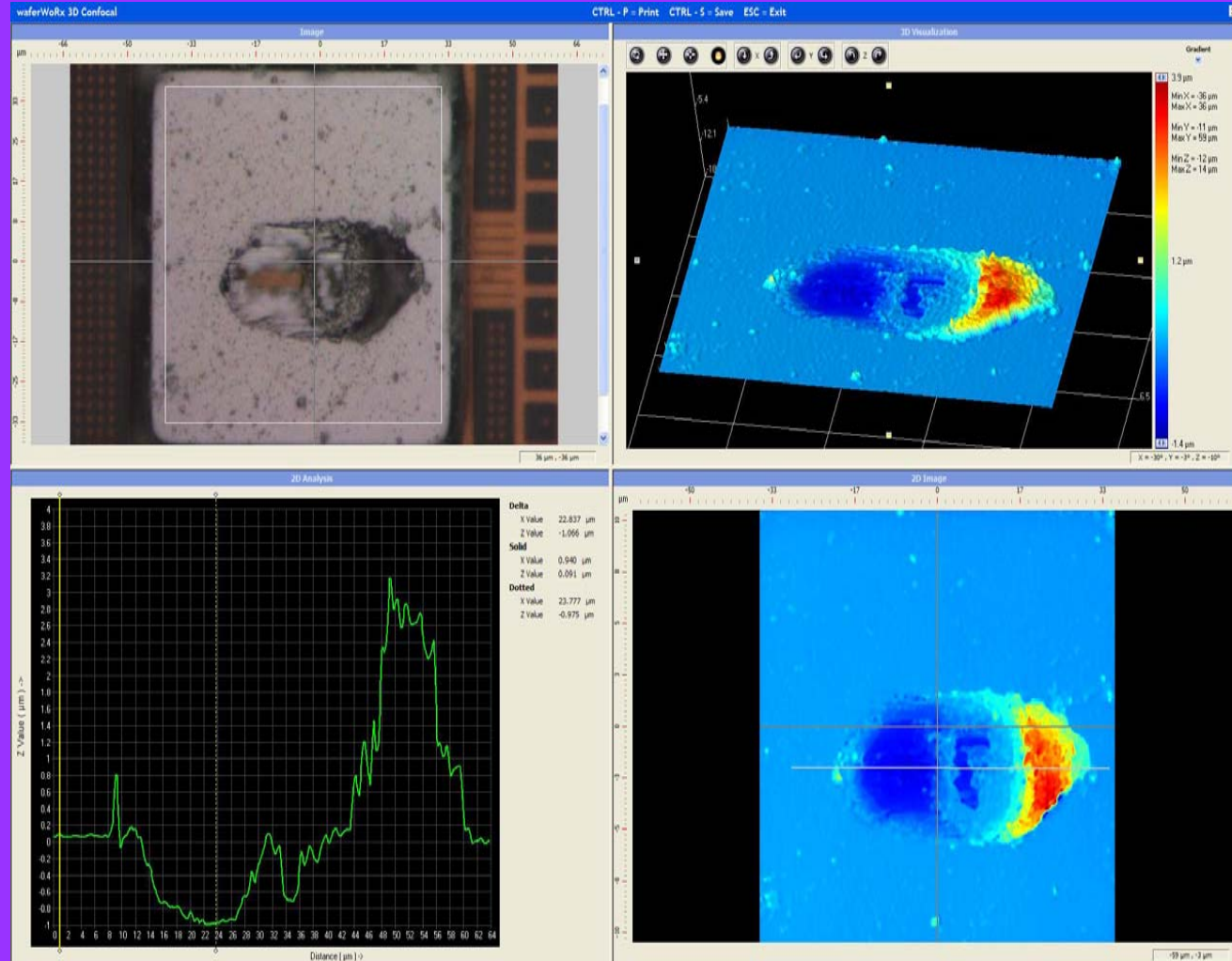
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waferWoRx - Spectral Scanning

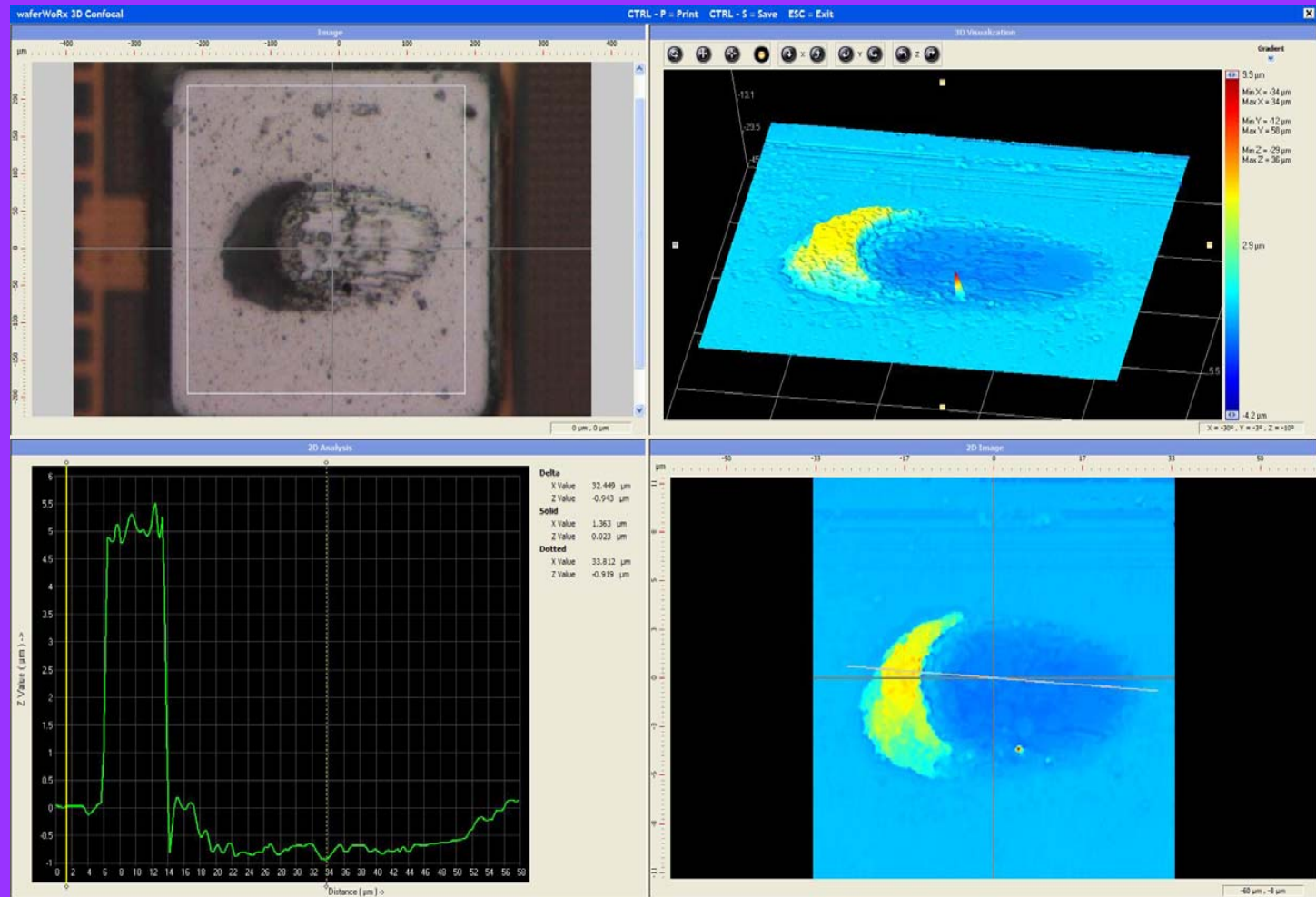


3-D Measurement - Punch Through



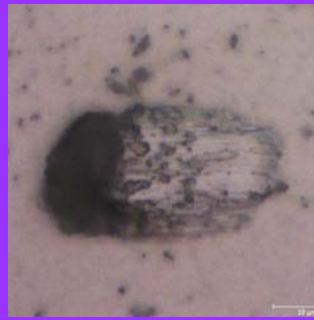
3-D Measurement – Deep Scrub

Scrub Depth Consistently 0.9u with no punch-through



Scrub Depth Repeatability

- Same Probe consistent in producing same scrub depth
- Same Probe consistently punches through to expose substrate



Scrub 1



Scrub 2



Scrub 1



Scrub 2

Bump Analysis Capability

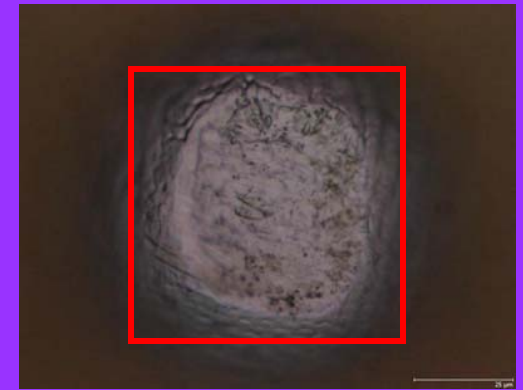
- Size and position of scrub
- Height of bump relative to the wafer surface
- Depth of scrub relative to height of the bump
- Planarity of the bumps



Unprobed

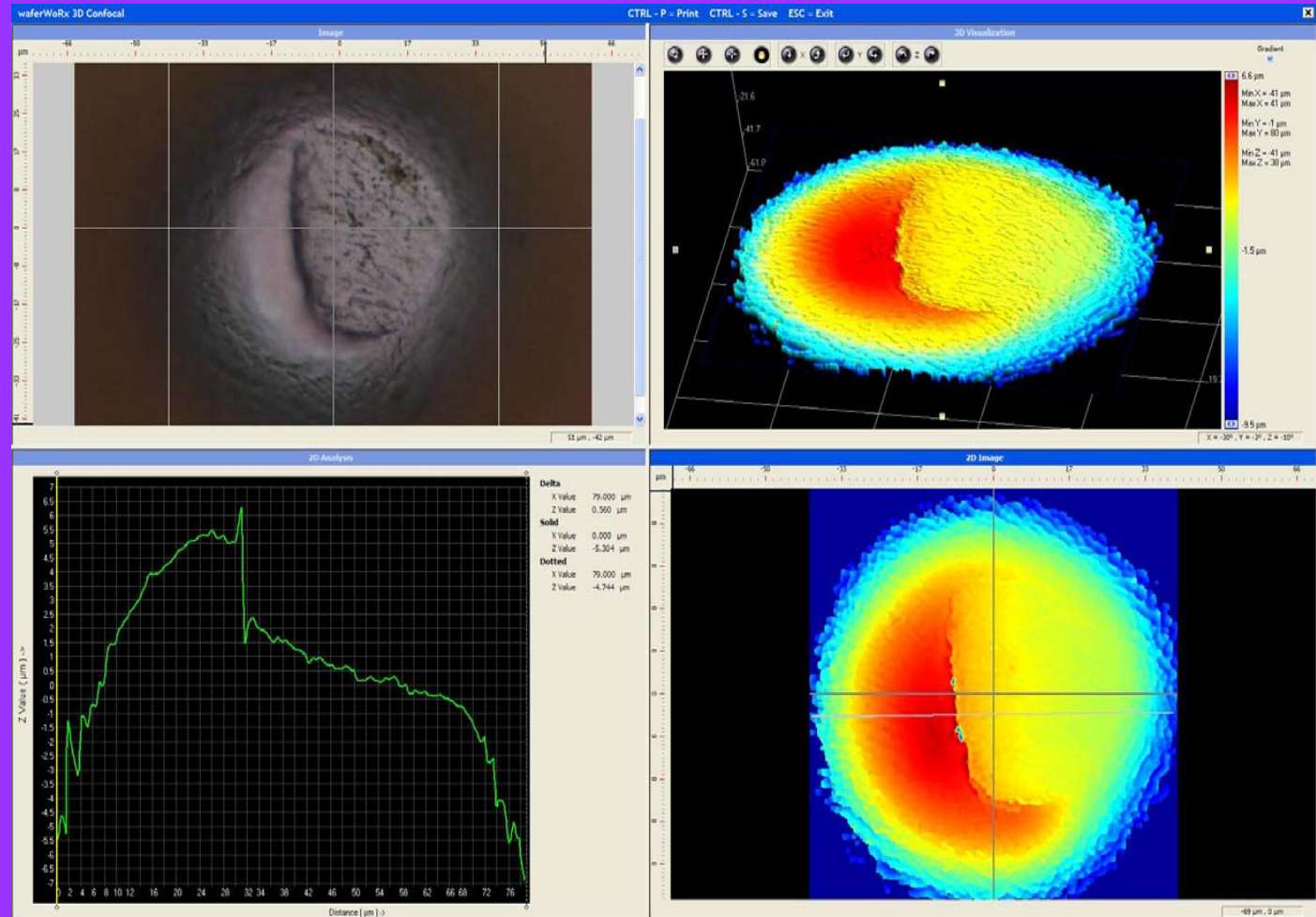


Off center
Scrub



Centered
Scrub

Bump Analysis 3D / 2D



Conclusion

- waferWoRx300 probe card measurements are correlated to the scrubs
- Controlling scrub length is important to controlling scrub depth
- Depth/Punch through is very repeatable for a probe.

